

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:  
David J. Keller

Serial No.: 09/458,875

Filed: December 10, 1999

For: **POLYSILICON ETCH USEFUL DURING THE  
MANUFACTURE OF A SEMICONDUCTOR  
DEVICE**



§  
§ GAU: 1763  
§  
§ Examiner: George Goudreau  
§  
§ Atty. Docket: 99-0738.00  
§  
§  
§

Commissioner for Patents  
Washington, D.C. 20231

**Certificate of Mailing (37 CFR § 1.8)**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, on or before the date below:

November 6, 2001

Date

Signature

Dear Sir:

**PETITION FOR EXTENSION OF TIME  
FOR THE OFFICE ACTION OF JULY 6, 2001**

Applicant hereby petitions to extend the period for response to the Outstanding Office Action mailed July 6, 2001 for one (1) month, from October 6, 2001 to November 6, 2001.

Accordingly, the Commissioner is requested to charge the requisite late fee under 37 CFR 1.17(a)(1), which is believed to be \$110.00, and any additional fee which may be required to Micron Technology, Inc. Deposit Account 13-3092, Order No. 99-0738.00. A duplicate copy of this petition is enclosed.

Respectfully Submitted,

Kevin D. Martin  
Reg. No. 37,882  
Micron Technology, Inc.  
8000 S. Federal Way  
Boise, ID 83706-9632  
(208) 368-4516  
Agent for Applicant

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